A in-line PECVD (plasma enhanced chemical vapor deposition) process is used to deposit a high performance AR+DLC coating for cell phone and tablet displays (Figure 1). The coating is a 7 layer stack consisting of a 6 layer AR of alternating SiN and SiO$_2$ thin films and a DLC top coat. The use of SiN as the high index layer benefits not only overall durability, but the low dispersion of SiN widens the process window needed to maintain neutral color. The optical performance inclusive of the DLC is less than 0.70% reflectance from 450-650nm with the a*, b* color range within +/-1.5 absolute value. Key characteristics of the PECVD process are long term process stability and uniformity, both critical to AR coating production. The high deposition rate allows a tool with one PECVD source per layer (more for the DLC) to produce 800km$^2$/year making large quantity production of small displays practical. The experimental data and results for optical measurements and durability and environmental tests are presented.

**UltraDep™ Technology**

General Plasma has developed a stable, high rate PECVD process for large area coating termed UltraDep™ [1]. In the process, the magnetically confined electrodes are hidden in a cavity and are not coated during a production run. The result is the PECVD process operates for days and weeks without process variation or loss of uniformity. Several patents have been granted and additional patents have been filed on both the process apparatus and method.

In addition to stable operation, UltraDep™ has other important features and benefits:

- Uniform deposition over large substrates to +/-1%
- Generation of an energetic ion flux to the substrate enables dense films on insulating substrates such as glass
- High deposition rate, 5-10x faster than reactive sputtering

**AR Coating with DLC Top Coat**

**Optical Performance**

The UltraDep™ PECVD process is used to deposit a 7 layer stack consisting of a 6 layer AR film and a DLC coating (patents pending). The 6 layer AR coating is composed of alternating SiN and SiO$_2$ thin films. The optical performance of the complete stack is less than 0.70% reflectance over the visible spectrum (450-650nm) with the a* b* color within +/-1.5 absolute value (neutral color). Figure 3 shows the reflection & color performance for the coating.
Figure 3. Anti-reflective optical reflection spectrum

Figure 4 overlays reflectance curves from different runs over 5 days of production. As can be seen, coating reflectance variations are less than 0.1% at all visible wavelengths.

The color of the AR coating is equally, if not more important than reflection performance. The ideal AR has a neutral color without a purple or green color bias. The AR+DLC coating achieves this ideal performance with a*, b* color within +/-1.5 absolute value. Two aspects of the technology make a neutral color AR possible: 1) Dense, amorphous SiN can be deposited with a sufficiently high index (>1.9) film for the AR design. SiN has lower dispersion than TiO$_2$ and this widens the color process window, and 2) the PECVD process is uniform and stable. Uniformity is +/-1% and this uniformity is maintained for long periods as shown in Figure 4.

Scratch Resistance and Environmental Durability

The DLC top coating applied to the AR stack provides resistance to scratching and environmental durability. DLC has been applied to glass before for these reasons [2]. The UltraDep™ process however enables conditions that make DLC coating practical for large area glass and other non-conductive substrates:

- With a refractive index (RI) of ~2.0, a DLC coating alone on glass can make reflection worse (depending upon DLC thickness). Because of the before mentioned sputtering uniformity challenges, a multi-layer AR coating in combination with a DLC has not been possible. With the UltraDep™ process, a DLC can be coated on top of a high performance 6 layer AR with little difficulty.
- DLC deposition, like other PECVD processes, presents source electrode coating challenges. As with the optical layers, the self-

The result is an extremely tough film that is harder and more scratch resistant than the native cover glass. Figure 5 compares the scratch resistance of chemically strengthened glass to GPI’s AR+DLC coated glass.

The hydrophobicity of the film surface is equally durable. Using an automated scratch tester with 0000 steel wool covering a 1cm$^2$ 'finger' and a 1kg weight, after more than 10,000 cycles the DLC coated AR stack shows no change in water contact angle (Figure 6).

Beyond scratch testing, the complete AR+DLC stack demonstrates excellent hardness and durability. A selection of results are:

- Nano-indentation test measurement of 9.4 GPa. (Note that this is a measurement of the underlying SiN/SiO$_2$ AR only as the DLC is too thin to be detected by this test.) For reference, nano-indentation test measurement of Corning’s Gorilla glass 3 is 8.6 GPa [3].
- In the Erichson pencil test, the DLC +AR hardness was 4.0N vs. 0.5N typical of evaporated or sputtered AR coatings.
- Adhesion to the base glass and between film layers is excellent. Using standard grid/tape test methods, a 1mm square grid was cut into the stack to the substrate and a pull tape test done. The adhesion result met a 5B (no visible delamination) on the test scale. After this the sample, with the cut grid, was immersed in boiling water for 10 minutes and then the tape test was repeated. Again, no adhesion failure was seen. Finally, sample is immersed in salt bath (150mg pure NaCl in 600ml of DI water) at 80°C for 24 hours and the tape test was repeated. This series of tests, boiling a grid cut sample, is extremely aggressive. Any columnar film structure, excessive hydrogen or interlayer defects will cause delamination when exposed to these tests.
- After repeated and extended contact with cleaning agents such as IPA and acetone, no loss of adhesion or damage to coating occurs.

Anti-Fingerprint Functionality

DLC is hydrophobic and therefore a natural anti-fingerprint (AFP) coating. In testing, the water drop contact angle exceeds 90 degrees and the roll off angle is 15 degrees. Figure 7 shows an S4 phone half coated with the AR+DLC coating. Both halves of the screen were equally

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smudged before this photo was taken.

While the water contact angle is not as high as that of evaporated fluorocarbon layers, DLC AFP properties are durable and relatively insensitive to chemicals and solvents.

Figure 7. Anti-Fingerprint demonstration shows top side AR+DLC resists fingerprinting (top half right side coated with AR+DLC).

Conclusion
For the first time a durable AR+DLC coating is available for cell phones, tablets and other displays. The AR performance, neutral color appearance and exceptional durability meet and exceed the tough requirements for mobile displays. A new in-line PECVD process, makes this coating possible and meets industry requirements for high volume/low cost manufacturing.

References

Authors
John Madocks
John founded General Plasma 17 years ago and has over 30 years of experience in the vacuum coating industry. He has invented several new plasma sources and has issued and pending patents for improvements to ion sources and sputter cathodes. Most notably John has pioneered the use of plasma enhanced chemical vapor deposition (PECVD) for large area substrates.

John is passionate about engineering and loves the challenge of product design. His drive for excellence has made General Plasma an innovation leader in the industry. These days he is excited about General Plasma’s progress in in-line PECVD, making films like the AR+DLC presented in this article. John earned his BS in Mechanical Engineering from the California Polytechnic State University at San Luis Obispo in 1981.

Phong Ngo
Phong joined General Plasma in 2006 after finishing his Electrical Engineering degree at University of Arizona. At General Plasma, Phong designed the electrical controls and software for a wide variety of vacuum equipment ranging from reactive sputtering controllers to glass coating production systems. In the last 2 years, Phong expanded his contribution to include thin film process development as the leader of General Plasma’s R&D group. In this role he has been the creative force behind the PECVD process advancements that make the AR and DLC coatings presented in this article possible.

For further information, contact John Madocks at jmadocks@generalplasma.com.